

M-MOS Semiconductor Hong Kong Limited

30 P-Channel Enhancement-Mode MOSFET

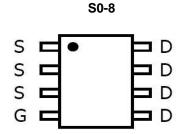
 $V_{DS} = -30V$

 $R_{\text{DS(ON)}},\,V_{gs}@\text{-4.5V},\,I_{ds}@\text{-4.0}=75\text{m}\,\Omega$

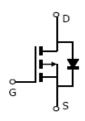
 $R_{DS(ON)}$, V_{gs} @-2.5V, I_{ds} @-1.0A = 119m Ω

Features

Advanced trench process technology High Density Cell Design For Ultra Low On-Resistance



Internal Schematic Diagram



Top View

P-Channel MOSFET

Maximum Ratings and Thermal Characteristics ($T_A = 25^{\circ}C$ unless otherwise noted)

Parameter	Symbol	Limit	Unit		
Drain-Source Voltage	V _{DS}	-30	V		
Gate-Source Voltage	V_{GS}	± 12	V		
Continuous Drain Current		I _D	-11	А	
Pulsed Drain Current 1)		I _{DM}	-50		
Maximum Power Dissipation	TA = 25°C	P_D	2.5	W	
	TA = 75°C	ı D	1.60		
Operating Junction and Storage Temperature Range		T_J,T_stg	-55 to 150	°C	
Junction-to-Ambient Thermal Resistance (PCB mounted) 2)		$R_{\theta JA}$	62.5	°C/W	

Note: 1. Repetitive Rating: Pulse width limited by the maximum junction temperature

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^{2. 1-}in² 2oz Cu PCB board



Package Data Sheet

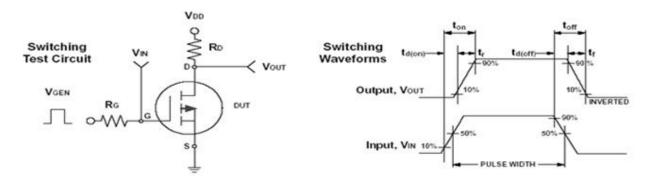
P-Channel Enhancement-Mode MOSFET

ELECTRICAL CHARACTERISTICS

Symbol	Test Condition	Min	Тур	Max	Unit
BV _{DSS}	$V_{GS} = 0V, I_D = 250uA$	-30			V
R _{DS(on)}	V _{GS} =- 4.5V, I _D = -4A		63.0	75.0	mΩ
R _{DS(on)}	$V_{GS} = -2.5V, I_D = -1A$		82.0	119.0	
V _{GS(th)}	$V_{DS} = V_{GS}$, $I_D = 250uA$	-1	-0.8	-3	V
I _{DSS}	$V_{DS} = 30V, V_{GS} = 0V$			-1	uA
I _{GSS}	$V_{GS} = \pm 12V, V_{DS} = 0V$			±100	nA
Q_g	$V_{DS} = -15V, I_{D} = 11A$ $V_{GS} = -10V$		13.2		nC
Q_{gs}			1.66		
Q_{gd}			1.55		
t _{d(on)}	V_{DD} = -15V, RL=15 Ω I_{D} = -1A, V_{GEN} = -10V R_{G} = 6Ω		8.88		ns
t _r			2.4		
t _{d(off)}			33.3		
t _f			3.2		
C _{iss}	$V_{DS} = -8V, V_{GS} = 0V$ f = 1.0 MHz		695		pF
C _{oss}			86		
C _{rss}			59		
•					
Is					Α
V _{SD}	$I_S = -2.7A, V_{GS} = 0V$				V
	$\begin{array}{c} BV_{DSS} \\ R_{DS(on)} \\ R_{DS(on)} \\ V_{GS(th)} \\ I_{DSS} \\ I_{GSS} \\ \\ Q_g \\ Q_{gs} \\ Q_{gd} \\ t_{d(on)} \\ t_r \\ t_{d(off)} \\ t_f \\ C_{iss} \\ C_{oss} \\ C_{rss} \\ \\ I_{S} \\ \end{array}$	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$

Note: Pulse test: pulse width <= 300us, duty cycle<= 2%

^{3.} Guaranteed by design; not subject to production testing



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P-Channel Enhancement-Mode MOSFET

Typical Characteristics Curves (Ta=25°C, unless otherwise note)

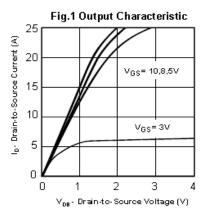


Fig.3 On-Resistance Variation with Temperature

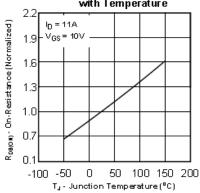


Fig.5 Gate Threshold Variation with Temperature

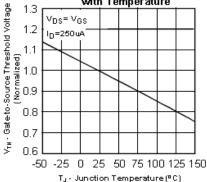


Fig.2 Transfer Characteristics 25

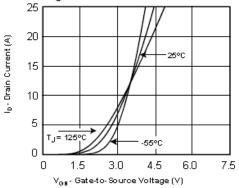
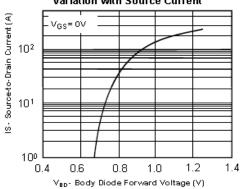
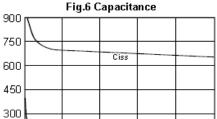


Fig.4 Body Diode Forward Voltage Variation with Source Current





150 Coss 0 o 5 10 25 15 V_{DB} - Drain-to-Source Voltage (V)

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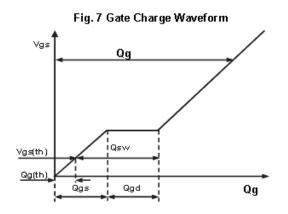
Capacitance, pF





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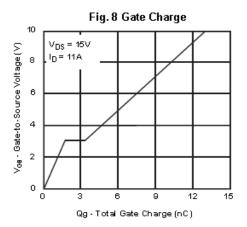
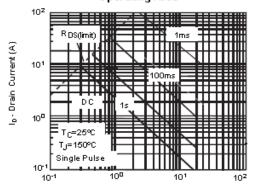
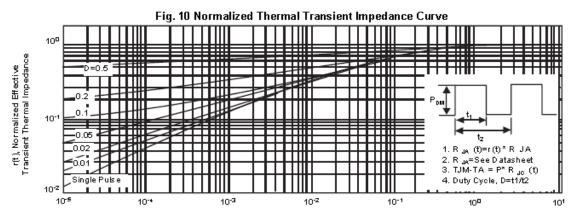


Fig. 9 Maximum Safe Operating Area



V_{DB} - Drain-to-Source Voltage (V)



Square Wave Pulse Duration (sec)

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Notice

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- 2. Stresses beyond those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. These are stress ratings only, and functional operation of the device at these or any other conditions beyond those indicated in the operational sections of the specifications is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

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